

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of:

Daniel MEISEL et al.

International Appln: PCT/EP2003/007819

U.S. Application No.: Not Yet Assigned

For: METHOD FOR THE PRODUCTION
OF PHOTORESIST STRUCTURES

Art Unit: Not Yet Assigned

Examiner: Not Yet Assigned

Confirmation No.: Not Yet Assigned

Atty. Docket No.: 31775-210910 RKCustomer No.: **26694****Preliminary Amendment**Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

Applicant requests entry of the following amendment prior to the examination of the above-identified application:

Claim Amendments begin on page 2.**Remarks** begin on page 6.